



When Failure Analysis Meets Side-Channel Attacks

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➤ *Introduction*

- Context
- Failure analysis
- Test vehicle

➤ *Light Emission as a Side-Channel signal*

- Background
- Experimental setup
- Results

➤ *Laser to improve Side-Channel attacks*

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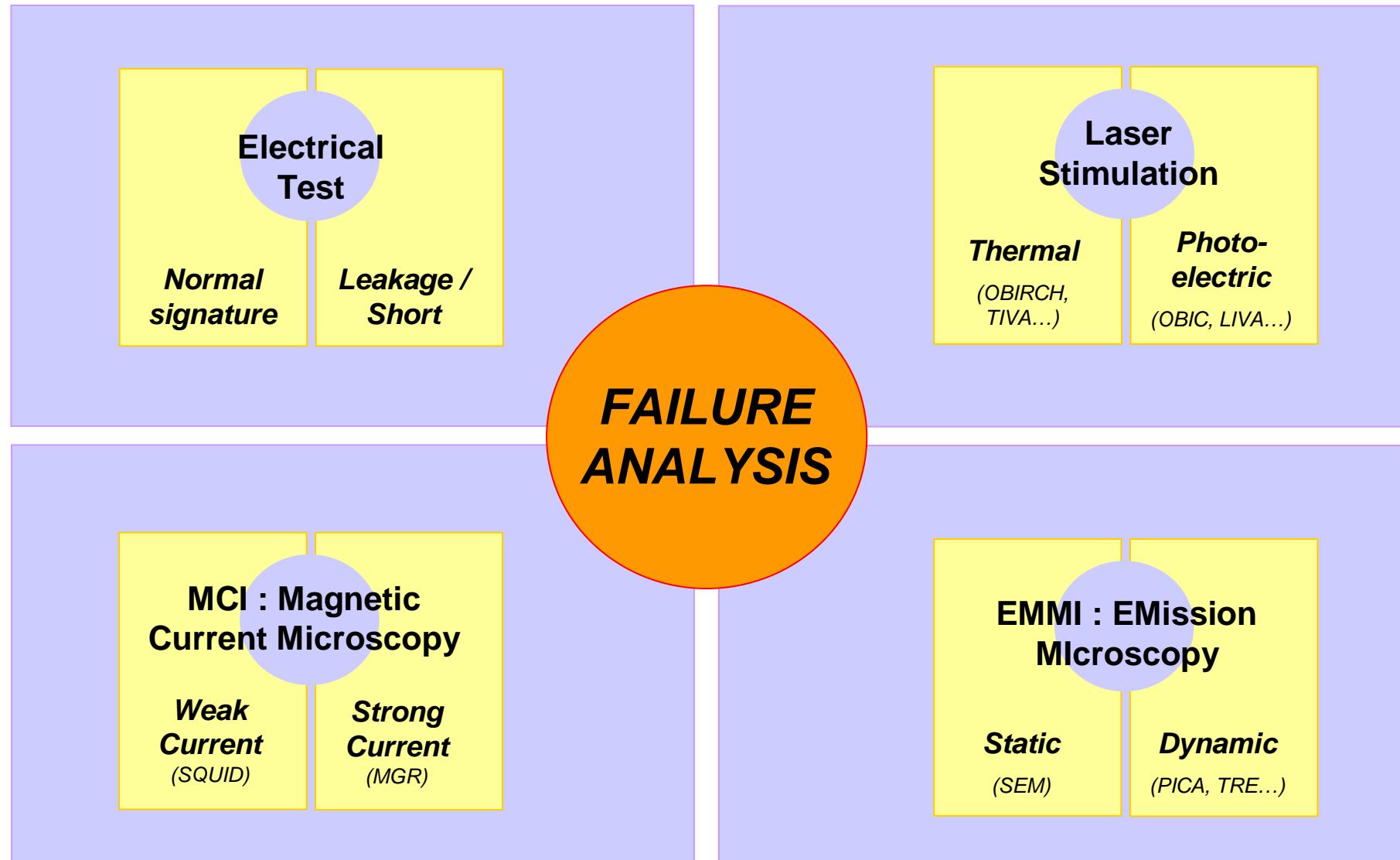
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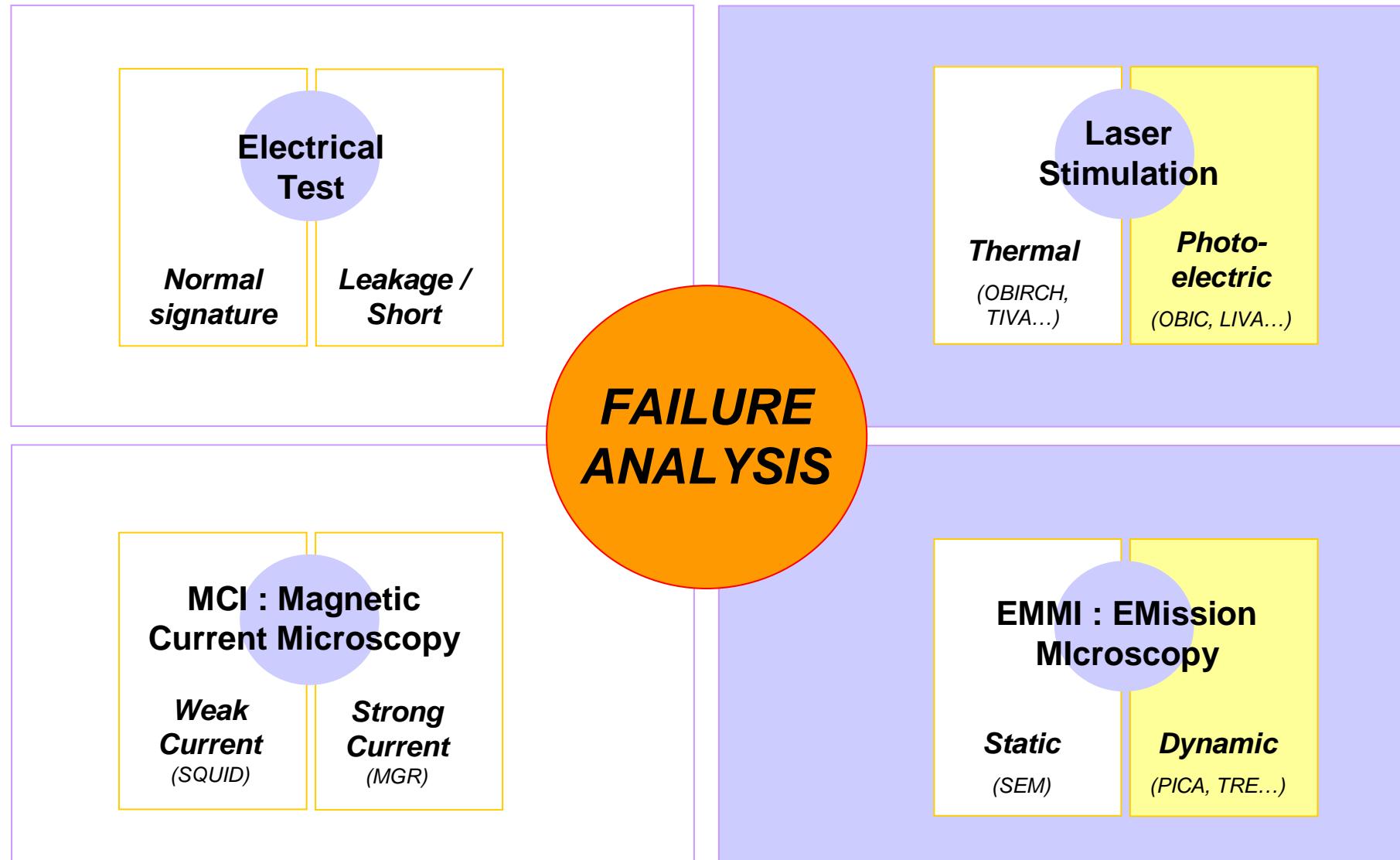


➤ *Partnership CNES / Thales :*

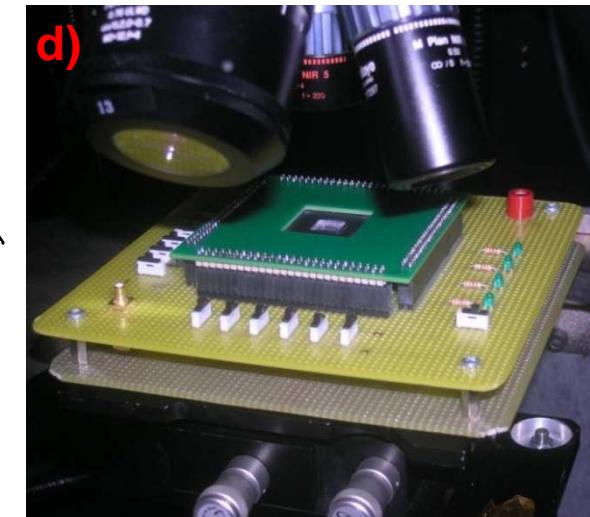
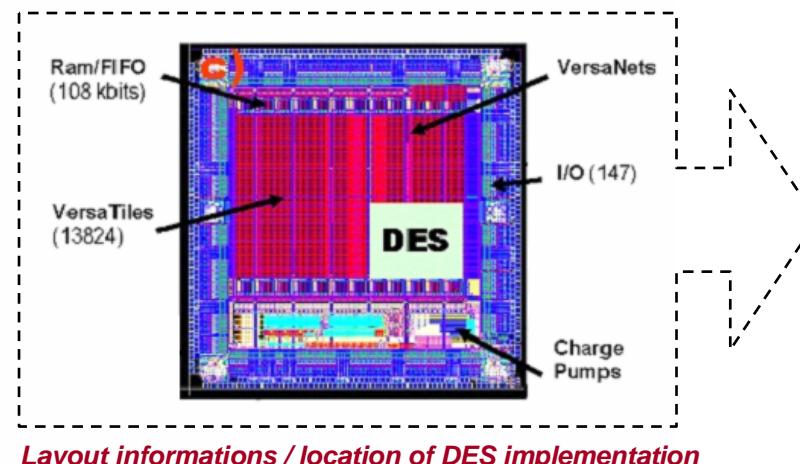
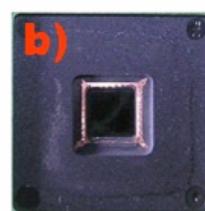
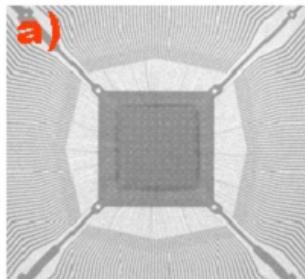
Common laboratory :

- **Failure analysis activity (CNES)**
- **Security evaluation ITSEF (Thales - CEACI)**
- **Electrical and physical testing (Thales - CEL)**





- Different view and informations about the **FPGA Actel® Proasic3e** :



- **Light Emission** : Experiment on the 1st DES round :

64 Messages Xor **random Subkey** => SBOX => Encrypted data

- **Laser stimulation** : Experiment on a full DES :

16000 Messages & **random key** => DES => Encrypted data

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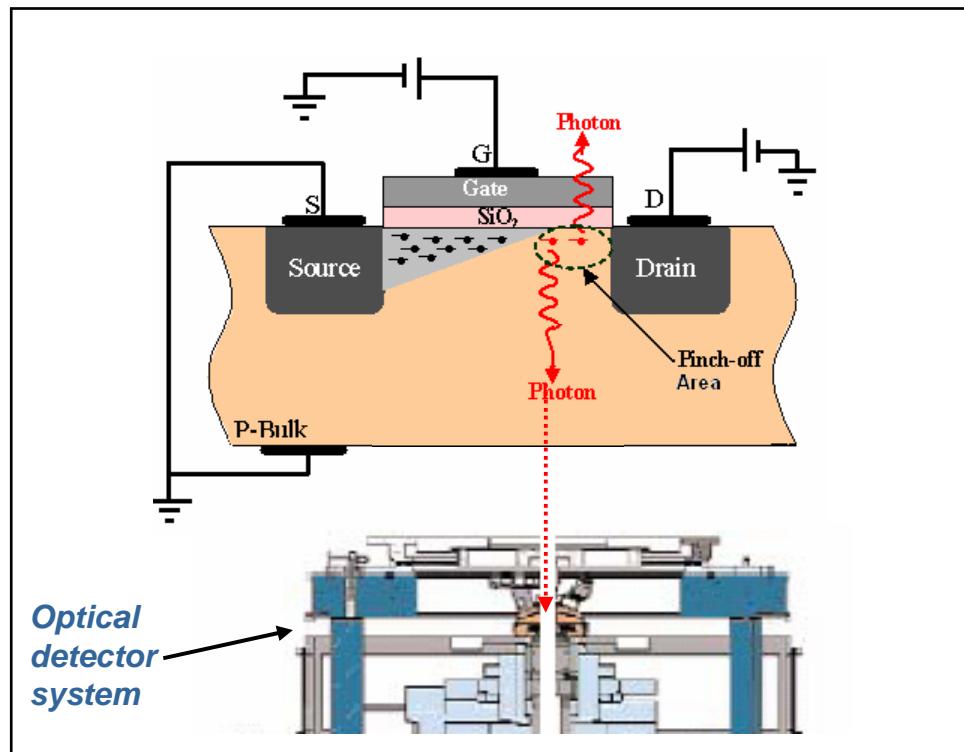
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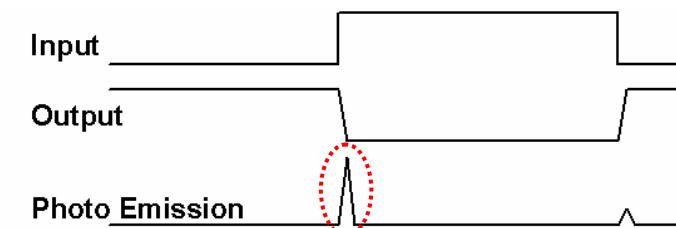
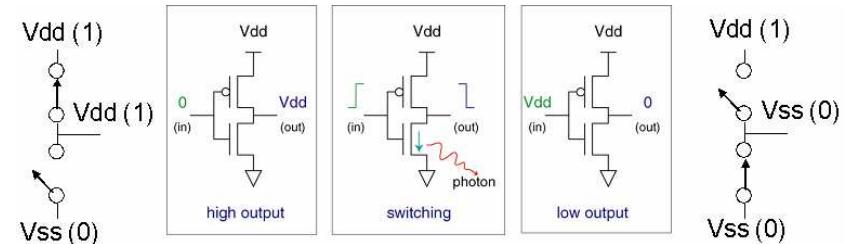
nMOS transistor



Photon emission depends on:

V_{GS} , I_{DS} , V_{DS} & transistor size

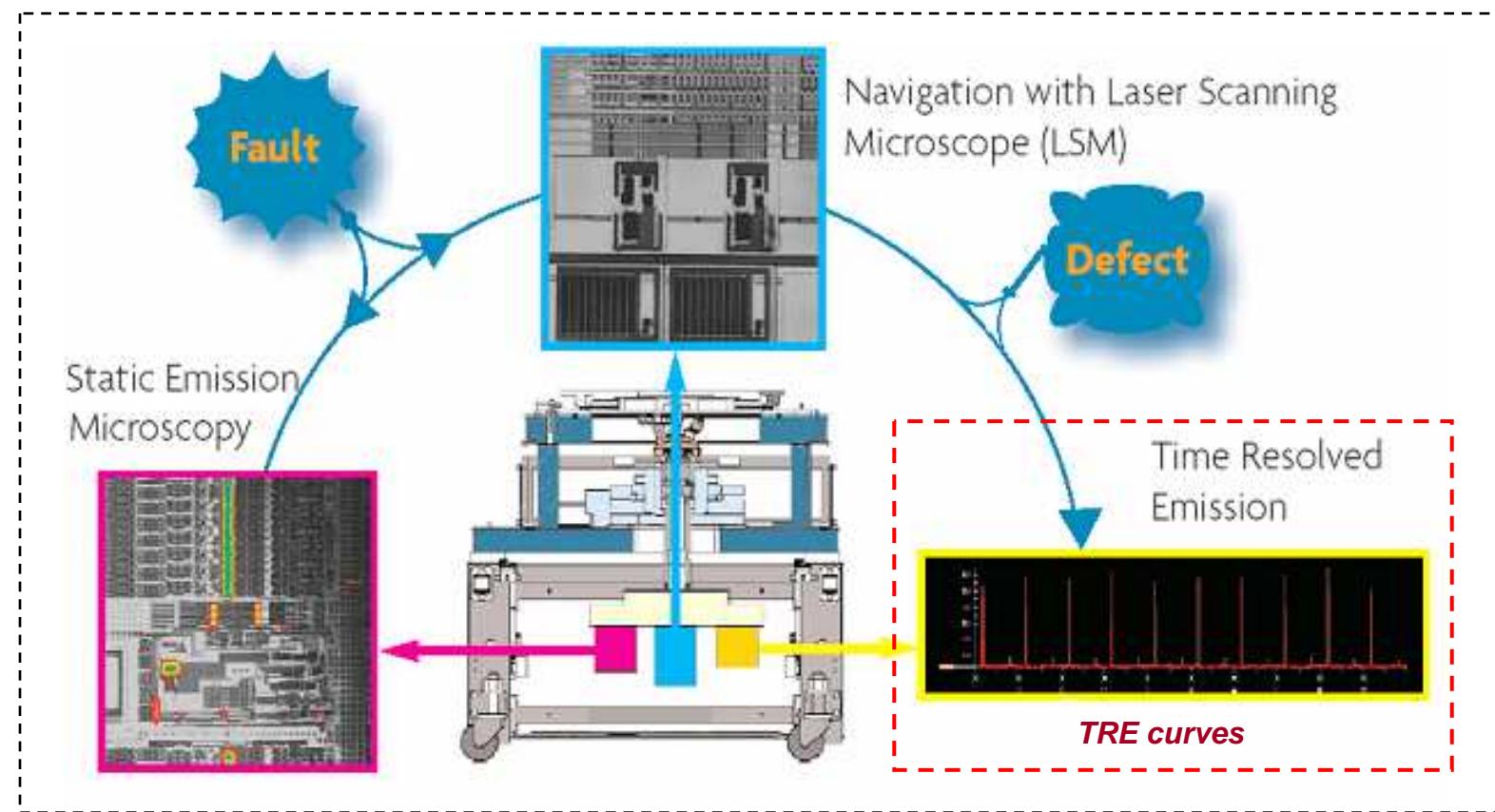
Inverter case



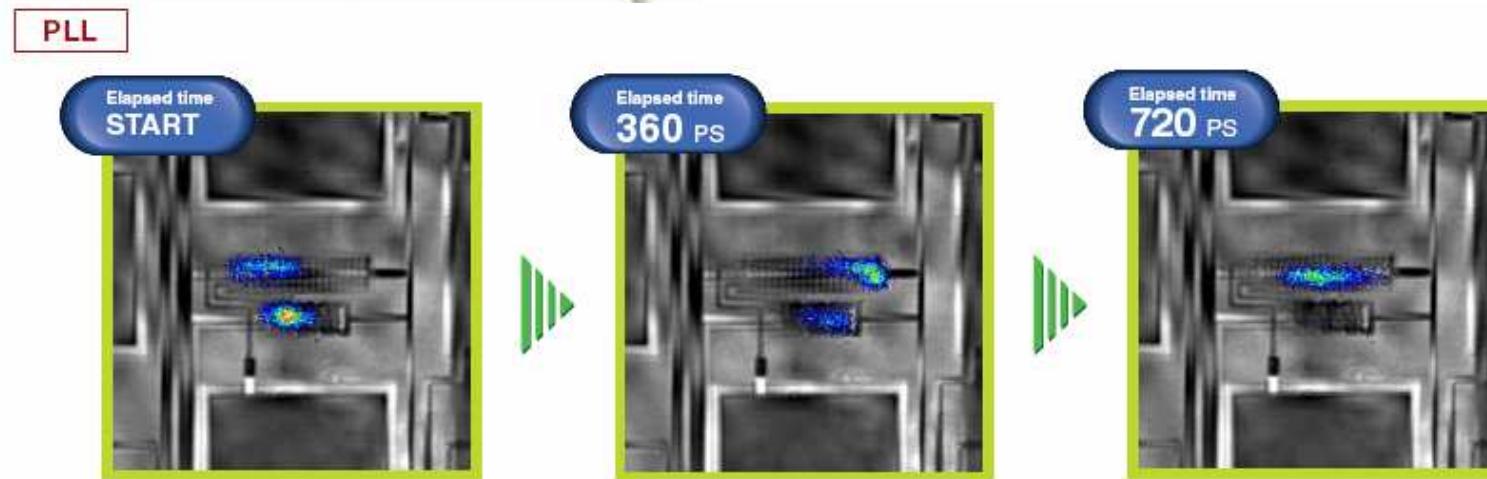
detector
system

- ✓ CCD silicon captor wavelength: $\lambda = 400 - 1200 \text{ nm}$
- or
- ✓ InGaAs captor wavelength: $\lambda = 900 - 1500 \text{ nm}$

Infrared : $\lambda = 780\text{nm} - 100 \mu\text{m}$
 Visible : $\lambda = 400 - 745 \text{ nm}$



- Many techniques were developed in failure analysis using EMMI:
 - Static Emission Microscopy (SEM) : spatial coordinate (x,y)
 - **Dynamic Emission Microscopy (TRE, PICA) : time information**



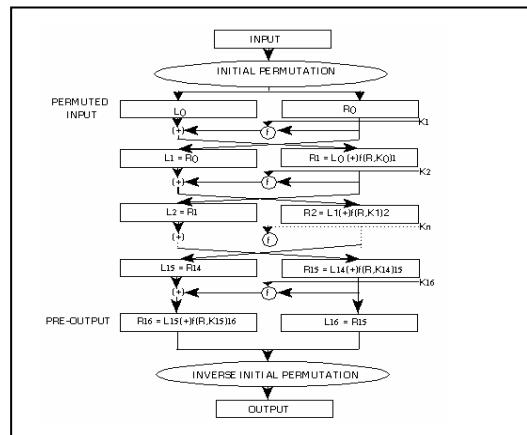
➤ **Camera types:**

InGaAs : 950nm to 1400nm / 640x480 / pixel size of 20 μ m x 20 μ m

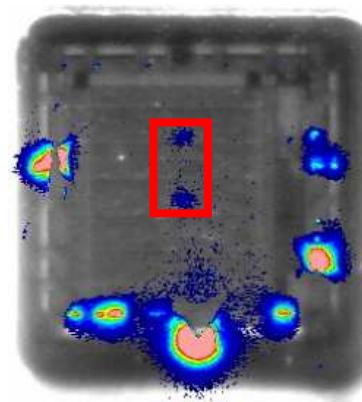
➤ **Objective lens:** 1x / 2.5x / 20x / 100x

➤ **Laser selection :** 1.3 μ m Laser (100 mW) / 1.3 μ m High Power laser (400 mW) / 1.1 μ m Pulse Laser (200 mW)

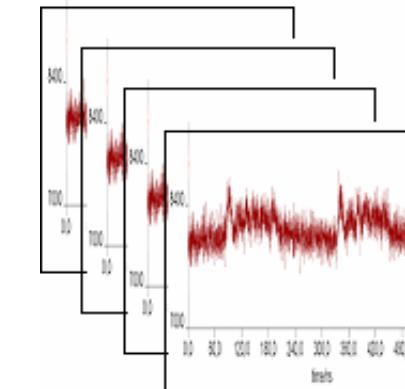
DLEA => Differential Light Emission Analysis :



Cipher algorithm implementation



SBOX Localisation

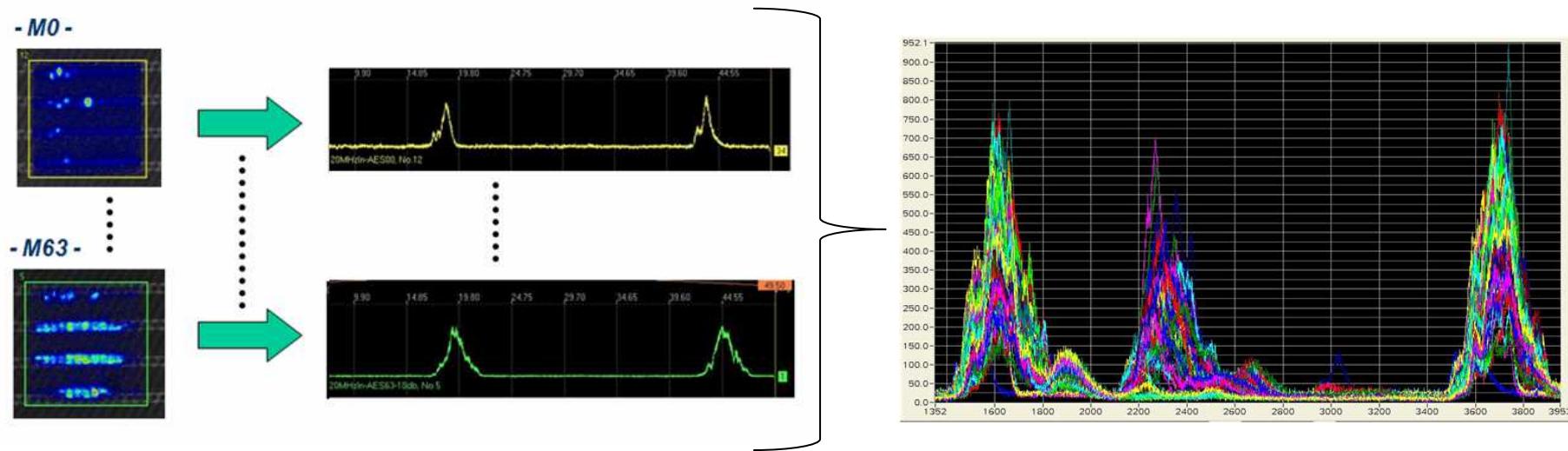


TRE curves

Mesuring light emission during device operation :

- Variation of plain text = time and space variation :
 - Differences between TRE curves
- Correlation between TRE curves and the Key used:

TRE curves (DLEA) = Power consumption curves (DPA)



- The photons emitted during 1 cycle clock are insufficient to be operated
- Acquisition system:

Camera ON [*Mx 00 Mx 00 Mx 00.....Mx 00*] **Camera OFF**

Photons Counting during 20 seconds

- 2 transitions : $0 \Rightarrow 0$ or $0 \Rightarrow 1$ **Hamming weight model**

1st output bit



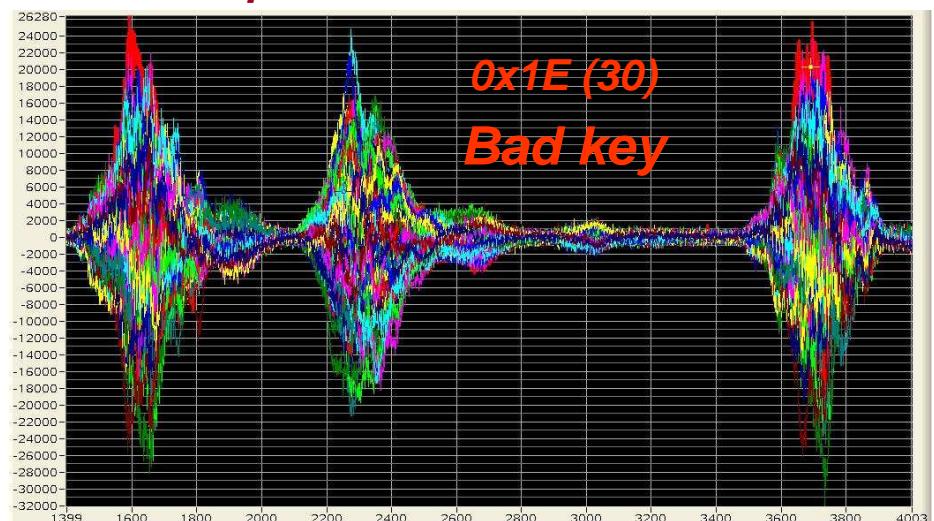
2nd output bit

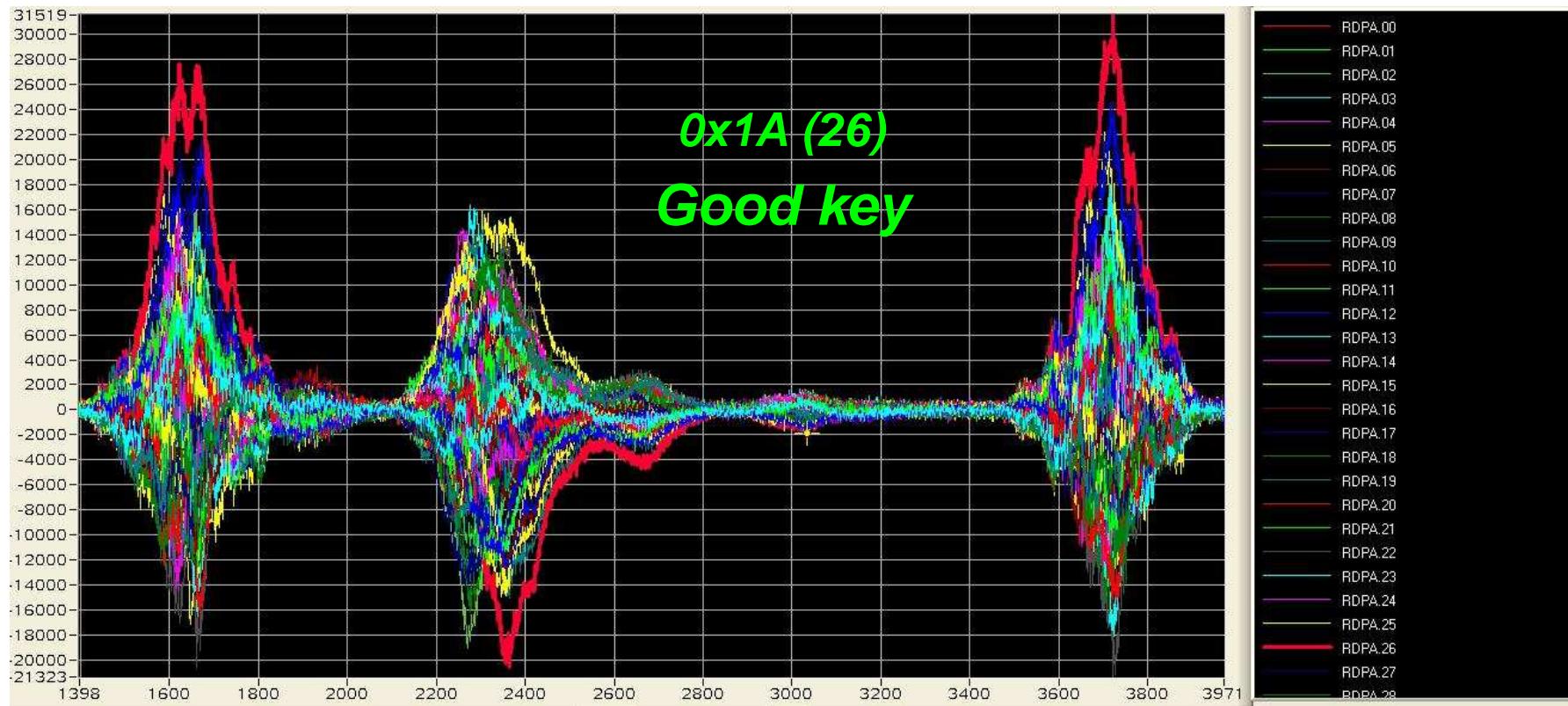


3rd output bit



4th output bit





Attack on the **3rd Bit** or **sum** of output bits reveal the good key

- In this case only time and photon counting data was used, but spatial factor can bring a lot of complementary information.

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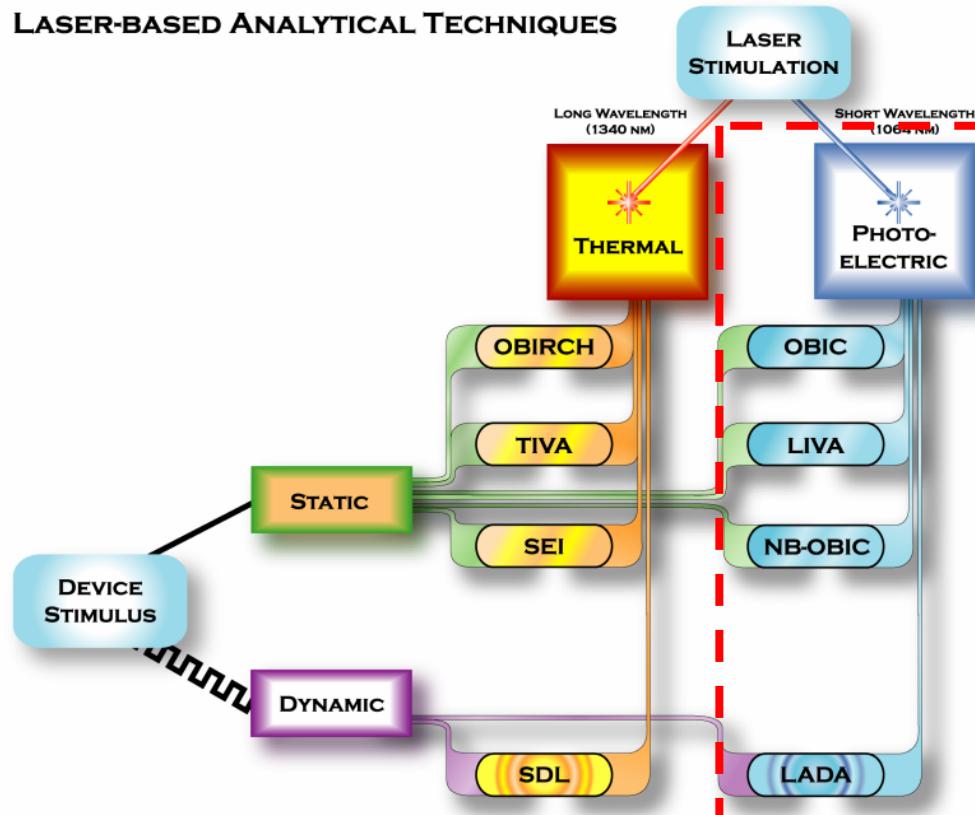
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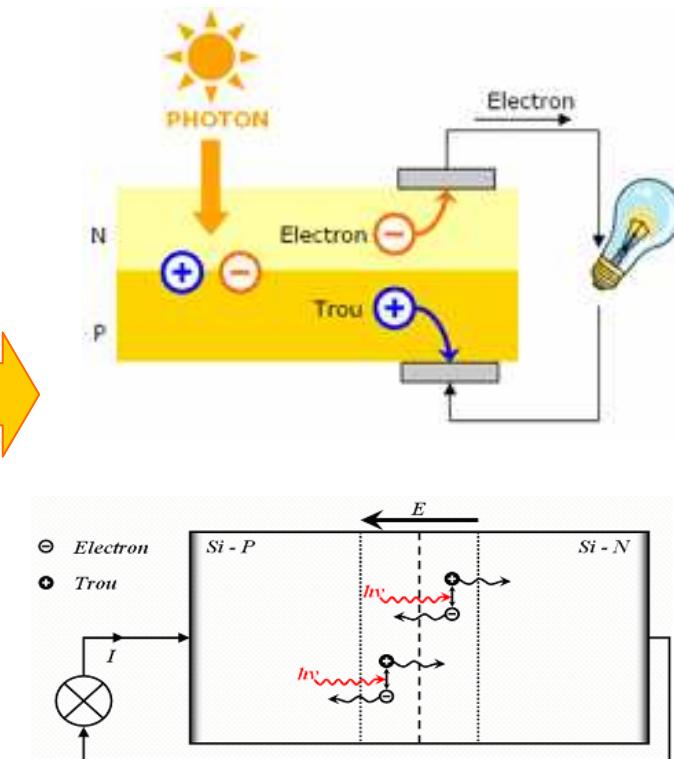
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LASER-BASED ANALYTICAL TECHNIQUES



Laser - Photoelectric effect :

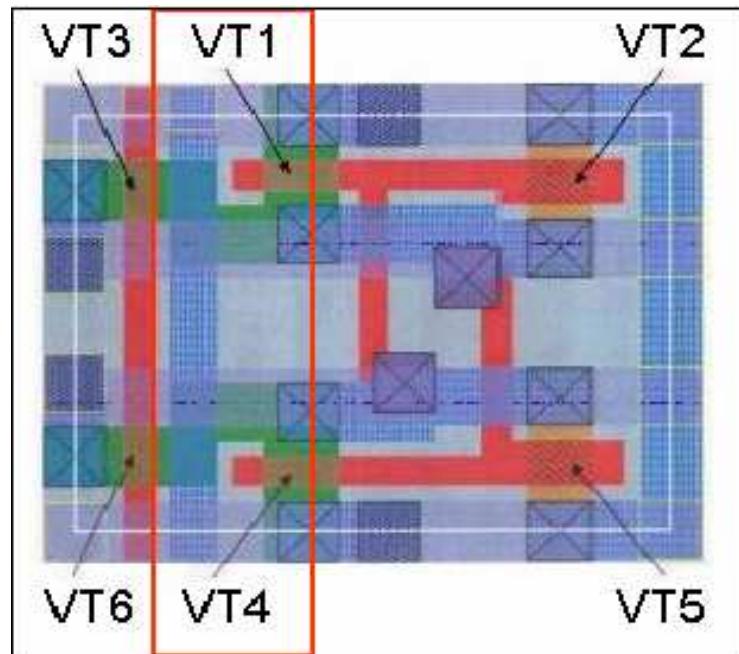


- Many techniques were developed in failure analysis using the 2 laser effects:
 - Thermal effect with a 1340 nm Laser (OBIRCH, TIVA, SEI...)
 - **Photoelectric effect with a 1064 nm Laser (OBIC, LIVA, SCOBIC...)**

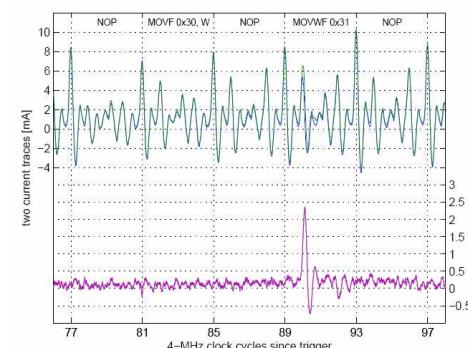
S. Skorobogatov : « Optically Enhanced Position-Locked Power Analysis »

➤ Spot Laser between 2 transistor of a SRAM cell:

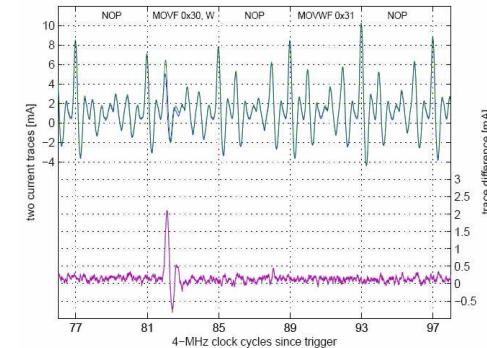
- **Increasing** power consumption of transistors targeted (local) inducing a global increase of the circuit



Layout of an SRAM cell

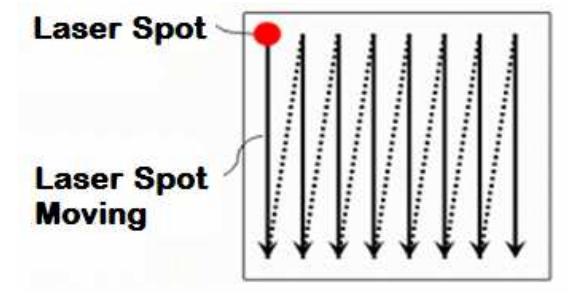
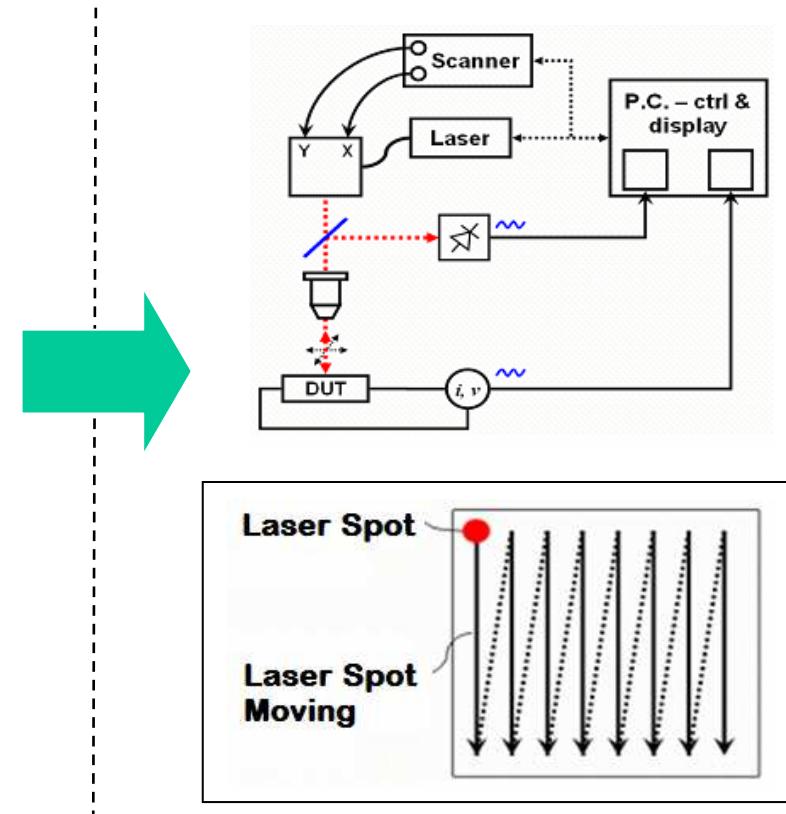


Write: (0x00 → 0xFF) and with laser on VT1+VT4



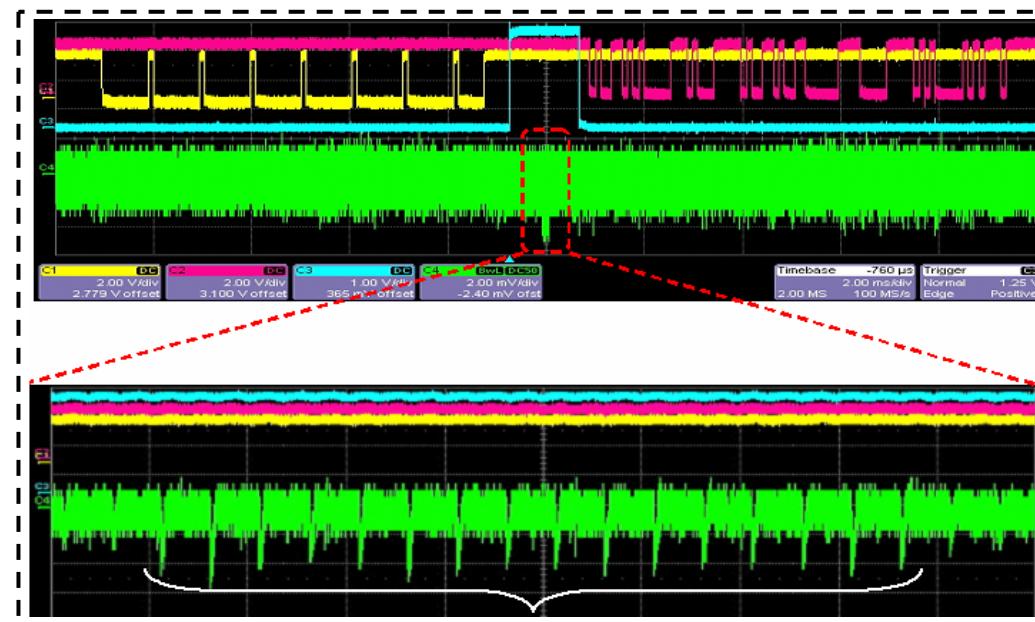
Read: (0xFF) and same with laser on VT1+VT4

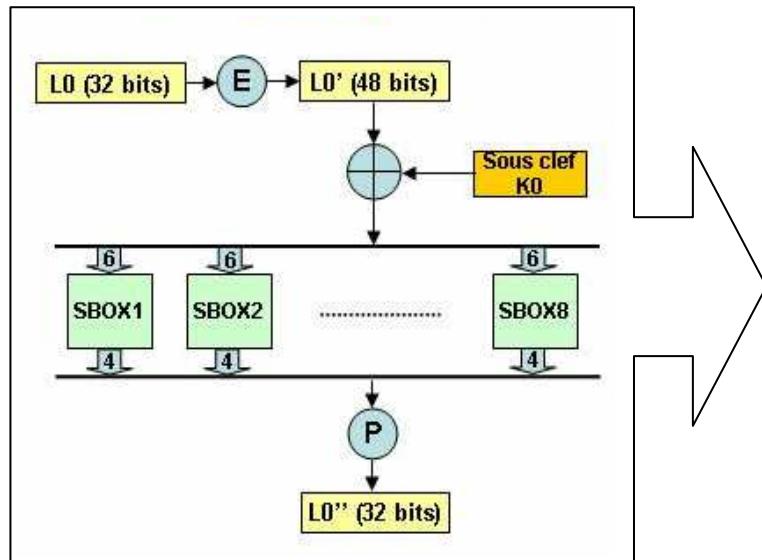
Laser source : 639 nm Power : 1 to 3 mW



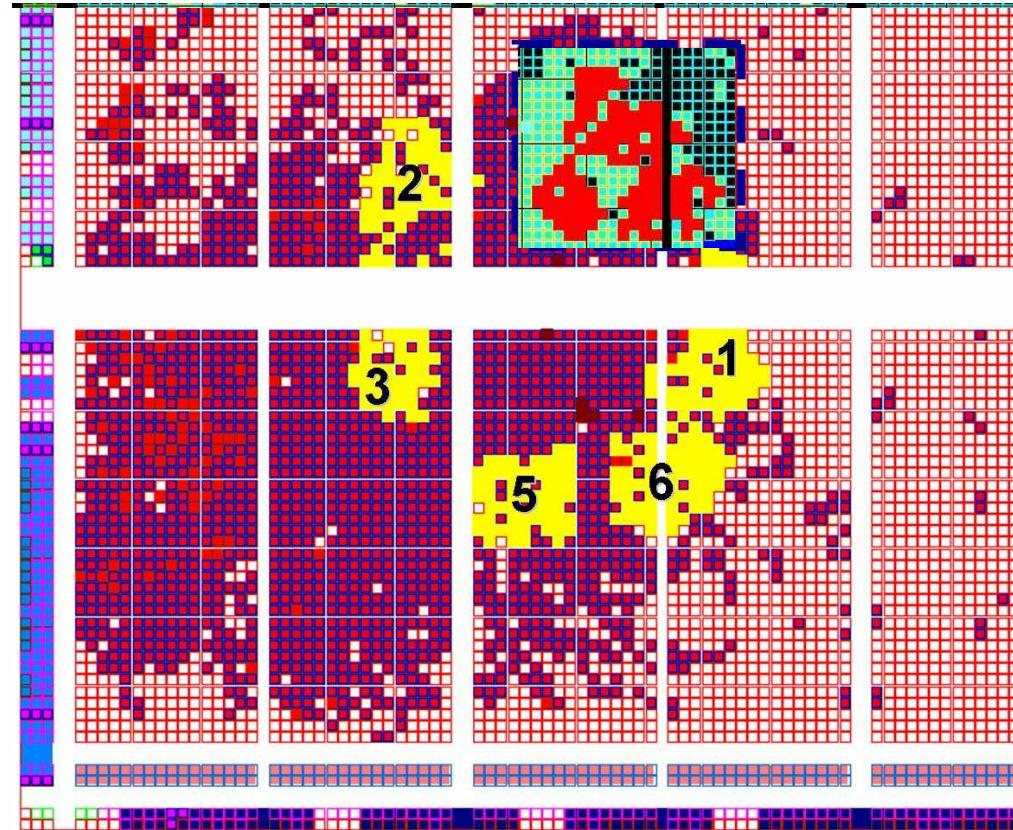
- **Laser selection :** 1064 nm (Photo-electric) / 1340 nm (thermal)
- Analytical capability for 45 nm. Inverted platform for easy ATE direct docking
- **Laser Scanning Microscope (LSM) for static and dynamic analysis**

- **1st step** : power consumption acquisition **without** laser stimulation on 16000 random messages.
- **2nd step** : power consumption acquisition **with** laser stimulation on same messages (same conditions).
- **3rd step** : Comparison of the minimum number of curves necessary to perform a successful DPA attack with & without laser stimulation.





Laser source : 1064 nm
Power : 10 to 12 mW



- Scanning laser of the area containing **SBOX 4,7 & 8** : local increase of the consumption
- Scanning laser in continuous until obtaining **16000 traces**

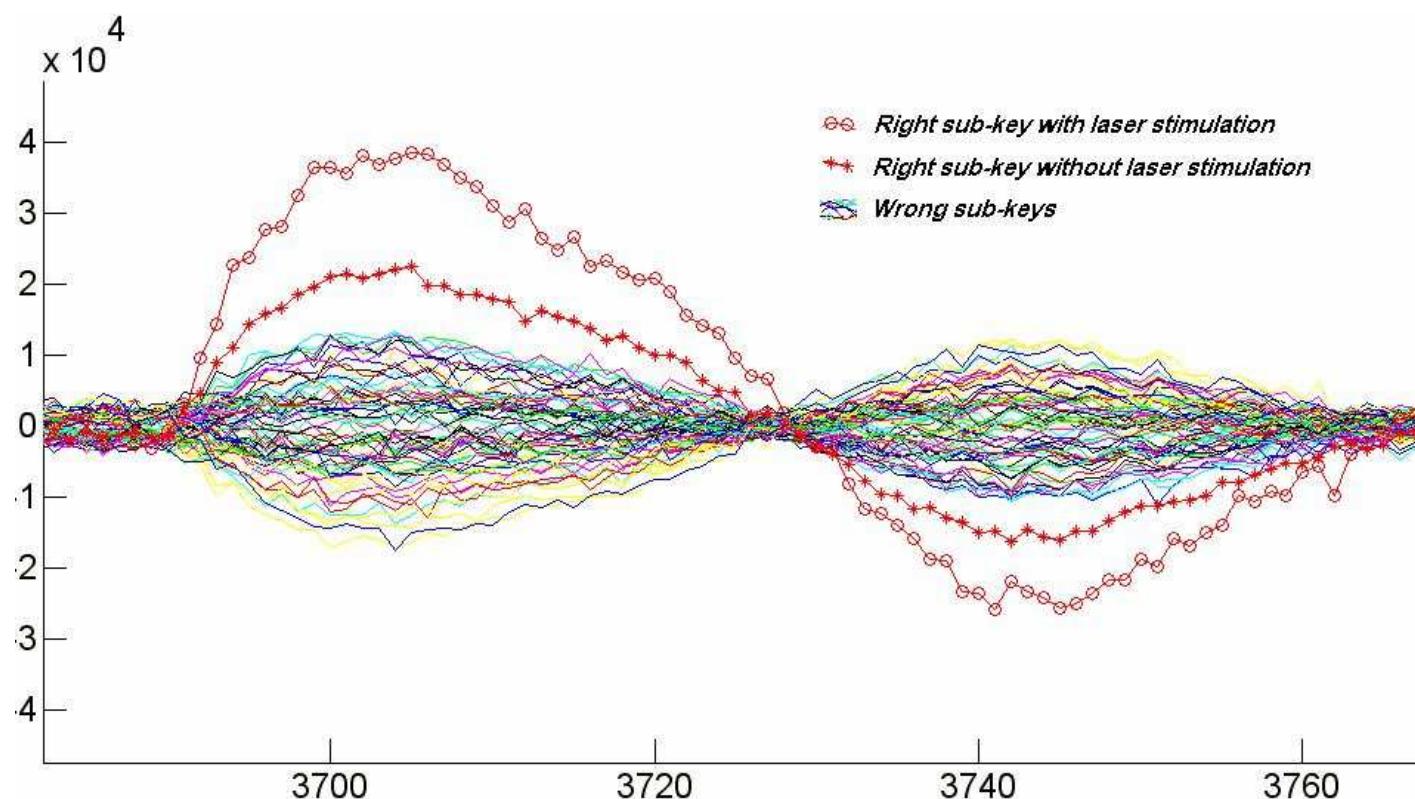
- Comparison between both DPA results with and without laser stimulation and numbers of curves necessary to perform the attack

	Bit 0		Bit 1		Bit 2		Bit 3	
Laser state	OFF	ON	OFF	ON	OFF	ON	OFF	ON
SBOX 4	~ 11000	~ 6500	~ 11500	~ 6500	NO	~ 9000	NO	~ 9500
SBOX 5	NO	~ 14500	~ 10000	~ 9500	NO	NO	NO	NO
SBOX 6	~ 11500	~ 9500	~ 10000	~ 7500	NO	NO	NO	~ 12500
SBOX 7	NO	~ 9000	NO	~ 8500	~ 10500	~ 6500	~ 11500	~ 6500
SBOX 8	NO	NO	NO	NO	~ 12000	~ 9500	~ 13500	~ 10000

- Conclusive results on **SBOX 4, 6, 7** and inconclusive on **SBOX 5, 8**

On SBOX 4,7 number of curves required are decreased by approximately 1/2

- **Amplitude** comparison between differential curves on the right key, with and without laser stimulation (DPA in 16000 curves on bit 0 of SBOX 4)



Benefit**Drawbacks***Light
Emission*

- Static acquisition :
 - Cipher localization
 - Spy memory activity
- Dynamic acquisition (TRE) :
 - Probe internal signal
 - Recover a subkey from DES

■ Acquisition method :
 Each messages need to be integrated on time to obtain a significant TRE curves.

- Lack of resolution on latest techno
- Sample preparation
- Equipment cost : $\approx 2 \text{ M}\text{\euro}$**

*Laser
stimulation*

- Local increase of the power consumption
- Reduce the number of power consumption curves necessary to perform an attack

■ Need a partial knowledge of the design / implementation

- Sample preparation
- Equipment cost : $\approx 500 \text{ K}\text{\euro}$**

■ Thank you for your attention

■ Questions?

Contact :

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